

Amendments to the Claims:

The following listing of claims will replace all prior versions, and listings, of claims in the application:

1. (Currently Amended) A method of manufacturing a ceramic film, comprising:
crystallizing a raw material including a complex oxide by subjecting the raw material to a heat treatment in an atmosphere pressurized to two atmospheres or more and containing oxygen at a volume ratio of greater than or equal to 1% but less than or equal to 10% or less, 10%.

2-3. (Canceled)

4. (Currently Amended) The method of manufacturing a ceramic film as defined in ~~claim 1.~~ claim 1,

wherein the heat treatment includes pressurizing to two atmospheres or more at least before raising a temperature.

5. (Currently Amended) The method of manufacturing a ceramic film as defined in ~~claim 1.~~ claim 1,

wherein the complex oxide includes Pb in constituent elements, and

wherein the heat treatment includes raising a temperature after pressurizing to two atmospheres or more at 100°C or less in a temperature raising process.

6. (Currently Amended) The method of manufacturing a ceramic film as defined in ~~claim 1.~~ claim 1,

wherein a temperature raising process of the heat treatment is performed in a pressurized state with respect to atmospheric pressure, and a temperature lowering process of the heat treatment is performed at a reduced pressure with respect to the pressurized state.

7. (Currently Amended) The method of manufacturing a ceramic film as defined in ~~claim 1.~~ claim 1,

wherein the raw material is a mixture of a sol-gel raw material and an MOD raw material, the sol-gel raw material including at least one of a hydrolysate and a polycondensate of the complex oxide, and the MOD (Metal Organic Decomposition) raw material including constituent elements of the complex oxide in an organic solvent.

8. (Currently Amended) The method of manufacturing a ceramic film as defined in ~~claim 1~~claim 1,

wherein the raw material includes the complex oxide and a paraelectric material having a catalytic effect on the complex oxide.

9. (Original) The method of manufacturing a ceramic film as defined in claim 8, wherein the paraelectric material includes an oxide which includes Si or Ge in constituent elements or an oxide which includes Si and Ge in constituent elements.

10-30. (Canceled)